IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:)
	Yuichiro Nakamura et al.) Examiner:) Group Art Unit:
Applica	ation No.:))
Corresp	ponding International Filing No.: PCT/JP2005/002209))
Filed:	Herewith)
For:	SPUTTERING TARGET WITH FEW SURFACE DEFECTS, AND SURFACE PROCESSING METHOD THEREOF)))
Commi	top PCT issioner for Patents ox 1450 dria, VA 22313-1450	

SECOND PRELIMINARY AMENDMENT

Sir:

Please amend the above-identified patent application as follows.

Amendments to the Specification begin on page two of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page three of this paper.

Remarks begin on page five of this paper.